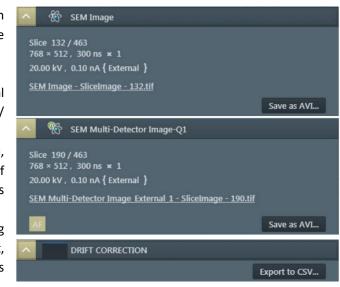
### Image series modules

The controls / information within these modules have the same meaning:

**Slice:** gives the serial number of shown image / number of all images

**Image:** Image resolution, dwell time, number of frames integration for this image

**Microscope**: Accelerating voltage, beam current, {detector type and its mode}



**Result:** Active item with the image series name – clicking it redirects you to the corresponding images folder.

Save as AVI...: clicking this button enables the creation of an AVI type movie from the image stack. A File dialog appears to specify a file name and select a directory for the resulting AVI file. ●

**AF / ACB:** informs, that the auto focus / auto contrast brightness image processing is in progress for the actual slice.

**Export to CSV...:** used to export the drift correction data to the format readable by most table processor applications.





### Focused ion beam

Introduction

Version 2 – May 2025

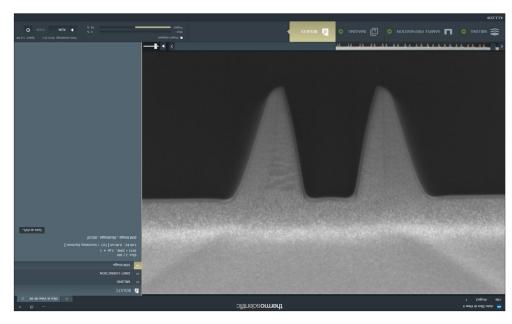
TOMOGRAPHY - SLICE AND VIEW

# Demonstration: Results

# Prerequisites: Tomography running or finished

# Collect your recorded data

This page is the same for viewing the results (images) as they come in during processing, as well as for viewing a previously executed project. The modules on the right side of the page show each resulting image series (as defined in the imaging page). The imaging area shows any image from the series by moving the slider at the bottom.





# Columns / Rows

The number of columns and rows of the grid used for tiling. An image/map will be acquired for each tile.

### **Tile Overlap**

Defines the percentage of each tile that will be overlapped during image acquisition to provide a reference area in the images for reconstructing a composite image of all tiles.

# Final Image Resolution (info field)

Shows the microscope UI settings of the image resolution.

# **Enable Stitching**

When ticked; this service stitches the image tiles to produce one large image.

Note: Tiling can only be enabled for SEM images and is recommended only for imaging with the electron beam perpendicular to the cut face.

reduced area is laid over the image to visualise which part of the field of view will be used.



Auto contrast brightness

When enabled, it applies ACB (Auto Contrast Brightness) to each image acquisition set in the Perform Every n<sup>th</sup> Acquisition. It determines whether or not an ACB is done before acquiring the image during the automated run. A reduced area is positioned over the image to visualize which part of the field of view will be used. Here, it is advised to use a part on the side of your cut face and not the fiducial marker, as the BVC signal of the marker (Pt) may not reflect the BVC signal of your object.

gniliT ●

When activated, a set of tiles of the cut face area is grabbed instead of a single image.



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รอุโมา โภรารข่ากป

Rule 1: Don't touch a control if you are not sure of the outcome of that action

Rule 2: Never, ever force anything beyond finger strength

Rule 3: Wear gloves when touching anything that goes into the

Rule 4: If in doubt, ask for help

### Auto stigmator

The auto stigmator functionality is performed before every n<sup>th</sup> acquisition of the series. A squared reduced area is positioned over the image to visualize the auto sigmator FOV (can be the same as the autofocus FOV).



### **Best Practices**

<u>Location</u> The auto stigmator functionality slightly adjusts the working distance, therefore: place the reduced area FOV at a location having the same

working distance as the cut face (see also remark autofocus).

Marker The reduced area FOV should contain structures in various directions to

ensure a good correction of astigmatism. Areas without any texture or areas with 1-directional patterns, such as lines, are not recommended.

The fiducial cross is usually a good choice.

Size The area must have an area at least 100×100 pixels.

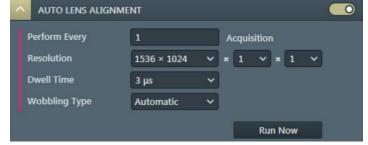
<u>Scan Rotation</u> Untick this box to simulate the behavior of Auto Stigmator functionality

in the UI (uses rotation), that changes scan rotation value.

Clicking the Run Now button starts the functionality immediately.

# • Auto lens alignment

The auto lens alignment functionality is performed before every nth acquisition of a series. A square



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Auto contrast brightness

egemi swods bne sgnittes berugifnoo	
performs an auto focus sweep with the	the color.
Perform Sweep or run now button	series of both sweeps distinguished by

"noisy" to the human eye. (low dwell times, low resolutions, high magnifications). The auto focus functionality is designed to work well even when the images appear There is always a trade-off between accuracy, speed, robustness, and sample exposure.

	of speed. Note that the coarse / fine sweep helps out here.				
<u>Step number</u>	higher number of steps increases the accuracy, but comes at the price				
	at the slight cost of accuracy and robustness.				
<u>Resolution</u>	lower resolution and smaller dwell times will increase acquisition speed				
<u>noitiso9</u>	place your marker on line with your FOV, not in front or behind				
<u>əmiT</u>	is mainly determined by acquisition speed and number of steps.				

Best practices Demonstration: Results ..... OЭ əd

Range



automatically the best result (i.e. the highest bar). Ideally, both the orange and blue focus. The higher the colored bar, the better the focus. The application selects The colored images obtained during the autofocus run indicate the success of the auto

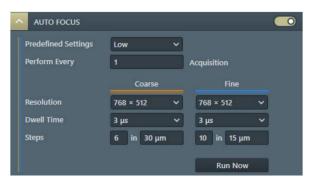
step size (i.e., range divided by steps) of the coarse sweep.

rule of thumb: the range of the fine sweep should be a few times the

	100	The second	TO THE PARTY OF TH		1720
The state of the s		N // 1-128	1/1/15		1/1/2-24
一位一位 人	2 42		46 46	146	
110 VIII 110 VIII	\$ 57/1 5 V/1		inca linea	19/16	100

### Auto focus module

The auto focus functionality is performed before every n<sup>th</sup> acquisition of a series. An orange area with a blue border is positioned over the image to visualize the aufofocus FOV. Position and size of the reduced area can be adjusted. The autofocus is based on "sweeping"



the working distance in a two-step approach over a specified range while measuring image sharpness. First a Coarse sweep (orange color) to get close to focus is perfromed, followed by a Fine sweep (blue color) to optimize it. Tune the parameters – the autofocus needs a good quality image - and run the auto focus prior to starting a project execution.

<u>Place the auftofocus window on a horizontal axis – same working distance – as your cut face (e.g. the fiducial marker).</u>

# **Predefined Settings**

(Low / Medium / High / Custom) are different preset settings to the multiple controls.

### Perform Every # Acquisition

Specifies how often the autofocus should be performed.

### Resolution

The pixel resolution of images acquired during the focus sweep.

### **Dwell Time**

The amount of time the beam dwells on each pixel when images are acquired during the focus sweep. The higher, the less noisy the images are and the higher the chance for a good autofocus.

### Steps

The number of working distance (WD) steps in which the range will be sampled: WD step size = range / steps.

### **Demonstration: Starting up Auto Slice and view**

### Prerequisites:

Running xT server Running UI

### Action:

Slice and View software

### Load the dedicated tomography software

To launch the application:

- Double-click the ASV icon on the Windows desktop,
- Or select the Thermo Scientific toolbar button / Auto Slice & View







The software opens. Place the window on the rightmost screen

### Y-shift correction

method by checking the radio button.

In perpendicular SEM imaging, the sample is tilted in such a way, that the plane of the cut face is perpendicular to the electron beam, that results in the most accurate image. Normally an electron beam imaging is under 52°, so each slice causes a little image shift. To compensate this behavior for every slice, activate this module and select a desired

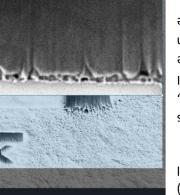


### Hid2 ms98

compensates an image shift by changing the beam focus. There is limited beam shift to make use of, and the detector mode also affects available beam shift.

# Pigital Shift

starts the Selected Area Scan for a corresponding image series, and compensates an image shift by shifting of this area. Below: the lower (clear) area is the actual selected



area, the area above (bluish) delineates, where the digital shift will take place.

Dimensions of these areas are set by an application, they are influenced by AOI dimensions. The image above shows the situation after clicking the Optimize Field of View button, causing extention of the AOI to fill the display optimally.

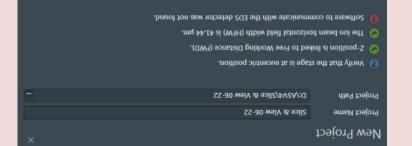
# Starting a new project

# Prerequisites:

- At Eucentric heigth
- Z is Linked
- HFW between 10 150 km

### Experiment: starting a new project

- 1. Load a sample onto the stage
- 2. Navigate to the feature of interest and place it in the center of the field of view.
- 3. Set the sample to the eucentric position.
- 4. Tilt the stage to 52°.
- 5. Ensure that the electron and ion beams are coincident.
- 6. Verify that the image shift, when changing the ion column aperture, is minimised. 7. Optimise electron beam focus.
- 8. Run the Link Z to FWD procedure.
- 9. Set the ion beam horizontal field width within the range  $10-150\,\mu m$ .
- 10. Select the Stage menu / Enable Safe Stage Moves item on the microscope UI 11. In the slice and view software, click the big + to start the new project effect.



- Enter an unique project name.
- Save on a folder in the SharedData drive. NOT on the local drive.

Demonstration: The milling page

### The alignment module

An automatic image stack alignment. It is used to get all of the images aligned with one another. The user specifies a unique feature to look for (tip: use the fiducial point) and then for each slice it beam shifts the image so that the fiducial point always appears in the same spot.



### **Image**

The image resolution and its bit depth (16 bit!).

# Acquisition

the dwell time, number of frames to be integrated for the images used to align the final cut face area during the automated run.

### **Find Fiducial**

Clicking this button positions the sample, performs auto-contrast and brightness if activated, and finds the fiducial marker. Alignment configuration is not complete until you click this button.

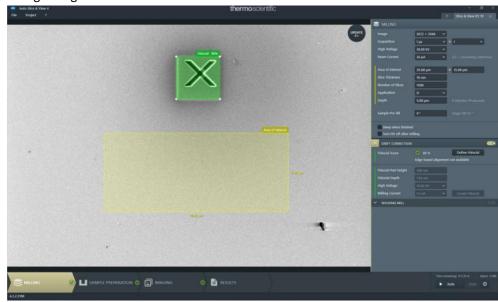
### Prerequisites:

Area of interest located, 52° xT location focused and stigmated

### Background on the ion beam

Set up the milling controls and the drift correction / fiducial parameters.

In the **ion image**, the slicing/milling area is indicated by a yellow rectangle. The fiducial point area is indicated by a red rectangle; when the fiducial point is defined, this area changes to green.



Controls

scanned for imaging (see below)

Selected Area Scanning

series.

Acquisition

lmage

(lalways 16 bit!)

if checked, only selected area will be

integration to be used for this image

integration and number of frames

the dwell time, number of lines

The image resolution and its bit depth

# Detector setup

The beam used by this acquisition type. Τype

# Voxel cube

setting of the isometric (cubic) voxel. settings. A tooltip gives a hint about stage position and tilt correction the resolution, HFW, slice thickness, The size dimensions are dependent on

# Acquire Every # Slice

.93ils "n acquired. You can e.g. only record every The interval between slices to be

A meaningful name for the actual image

series.

Name



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### thickness. height/slice of seoils ĴΟ unmber Changing the height will adapt the

# number of slices to match the new Changing this value will adapt the The targeted thickness of each slice. Slice Thickness

thickness.

# number of slices. site to match the slice thickness and the yalue will adapt the height of the milling automated slicing phase. Changing this The number of slices to be made in the **Number of Slices**

# Application

# investigation. Typical Pt Deposition. appropriate for the sample under si fat noitealige la A GIS Material

# and 100 µm typing a value, typically between 0.5 by application, but it can be changed by sample geometry, etc. The depth is set depending on the kind of sample, The relative depth of the slicing area, Depth

# project has been finished. Force the system to sleep after the Sleep when finished

# Turn HV off after milling

# milling < 20 nm slice thickness. Consider selecting a higher resolution if the more image detail can be seen. of pixel rows. The higher the resolution, as: number of pixel columns x number described by the pixel count in an image to grab the drift correction images. It is The resolution of the image is to be used Image

# images and the number of frames. The dwell time is used to acquire the Acquisition

# The ion beam accelerating voltage. **Aigh Voltage**

# Always 30 kV!

# An 2 bns 2.0 neetween 5.5 and 5 nA time should be about 1 minute. of thumb is that milling time + amit anilling time the bottom right of the module. The rule milling time for one slice is indicated at of image resolution. The estimated guard against sample damage and loss reasonable time, but low enough to high enough to mill the sample in a milling (and imaging!). Select a current The ion beam current to be used for Beam Current

as defined by the yellow rectangle. The width and height of the slicing area Area of Interest (width x height)

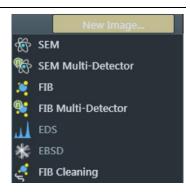
are used.

### Imaging controls

# **Acquisition types**

There are several possible types of acquisition selectable from the drop-down menu when clicking the New Image... button. By selecting any item, a new line (an image series that will be taken every slice) is added to the list, with the corresponding settings.

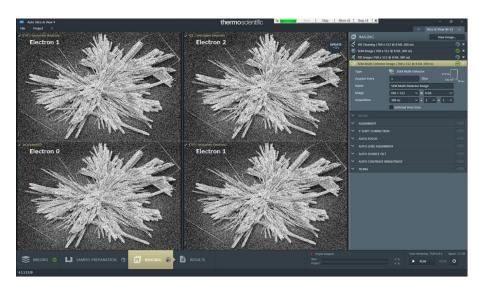
For the xT UI detectors (ETD, T1, T2,...), select the SEM Multi-Detector



### Multi-detector

This allows the selection of the quadrant that contains meaningful detectors.

Assuming the detectors are set up in the microscope UI, select the desired display(s) to include by checking its check box at the top-left corner. All selected displays must have the same beam (e-beam). By clicking the update button, the settings are updated and the image(s) is/are acquired in it's associated display.



Only used with a rocking mill. It switches off the ion beam accelerating voltage during a long-lasting electron beam

imaging (when the screen resolution and dwell time are set high).

Note Y-shift correction and compensation for the change in the Working Distance in the SEM images through the slicing job will fail, if a sample Pre-tilt is not set up correctly

### Drift correction module

FIB drift correction is needed for accurate processing results: a higher slice thickness accuracy and placement of individual slices can be achieved. It refers to the placement of the pattern for milling, not image drift.

A fiducial point is used for FIB drift correction during the entire slicing process.

### **Position**

The position of the fiducial point has to be some distance apart from the milling, but also within the imaging area borders. Ideally, it is placed right or left of the region of interest.

# **Fiducial Pad Height**

The deposited height of the protective Pt layer, wherein the fiducial point will be milled. Defaults are rather low.

### **Fiducial Depth**

The depth of the cross patterns.

# **High Voltage**

The ion beam voltage used to mill the cross patterns, ie. 30 kV

# **Milling Current**

The application should suggest a suitable milling current according to the fiducial rectangle size

# Demonstration: Imaging

# Prerequisites:

At least trenches and rough-cut milled.

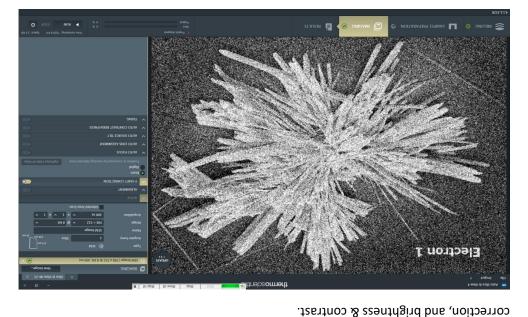
# Set up the detectors

Before proceeding with the items on the Imaging page, make sure the site is prepared for imaging. In the xT UI:

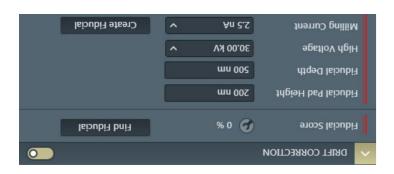
 ${\tt L}$ . Check and, if needed, adjust the microscopy conditions such as accelerating voltage,

beam current, and detectors for each display.

2. Optimise the imaging parameters such as lens alignment, focus, astigmatism



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# Experiment: Creating a fiducial marker

1. In the microscope UI, optimise the ion beam imaging parameters using the current you have set in the AS&V beam current settings (usually 0.5-5 nA). Adjust stage position and magnification so the region of interest is centred and sufficient space around it is available for a fiducial marker.

### 2. In the AS&V, click Create fiducial.

After completion, the fiducial marker will be searched for, and if successfully found, the software will proceed to the Sample Preparation page.

If the fiducial marker could not be found, optimise the fiducial point image by using the microscope UI and use the find fiducial manually.

# Manually finding the fiducial point

If the marker could not be found automatically, try a slightly more manual approach.

# Experiment: Manually finding a fiducial marker

1. In xt UI, optimise the ion beam imaging parameters using the current you have set in the AS&V beam current settings (usually 0.5-5 nA). If needed, increase the scan time.

2. In the AS&V UI, click the update button to refresh the ion beam image.

4. Manually resize and reposition the yellow box to cover the cut face area of interest.

- The AOI Overlap Slice Count text area specifies the number of GCP slices that overlap the bottom of the area of interest. If you stop the milling within the area of interest, the software will know where to begin during the automated slicing process.
  - High Voltage / Beam Current

The ion beam voltage / current to use when milling the Trench cuts, Rough cut, and Anti-Shadow Side Wall. (Note: the voltage and Beam current of the green clean pattern are set on the milling page)

Depth

The depth of the selected milling pattern area

Anti-Shadow Side Wall

Mills an anti-shadow angle trench for EBSD processing.

**Experiment** 

Click the Prepare Sample button to start the milling of all selected options.

5. Then click the Find Fiducial button. A new image will be grabbed to determine the Fiducial Score (in %) of the selected fiducial point. The higher the score, the better the fiducial point.

If the fiducial point is found, the software stores acquisition settings to use when locating the fiducial point during the automated run. From now on, the fiducial point is locked in; the yellow box can be resized but cannot be moved.

Rocking mill (optional)

Vertical direction milling is a common practice used by FIB for milling a series of 2D slices. It achieves milling in two different directions alternatively (under/overtilt) with a defined angle away from either side of the vertical milling direction to suppress a curtain effect.



<sup>&</sup>lt;sup>1</sup> If you are watching the milling process on the microscope UI and you decide that enough of the GCP has been milled, you can stop the milling at the end of the actual slice by clicking the Abort button.

### Protective Layer

Selecting this option deposits a protective Pt coating over the intended milling area. Typically, this is done manually before.

# Left / Right Trench

The trench cuts provide a place for material to be deposited as slices are milled away from the area of interest during the automated run. They are represented as blue rectangles to the right and left of the yellow milling area rectangle. Mills standard cross sections to produce the rough cut and trench cuts.

### Rough Cut

The rough cut exposes the front face (= the cross section) of the feature of interest for electron beam imaging. Its size and location are represented as a blue rectangle on the ion image.

### Green clean pattern

A Green Clean Pattern (GCP) is an optional polishing step of the sample cut-face for immediate data acquisition by milling away a user-defined number of slices at low voltage and current. The depth is the same as the standard slice depth (as set in the milling page). The GCP area is represented by a green box in the image area.

- The milling occurs at the voltage, current, and depth specified on the Milling page.
- The width of the green box is restricted to be the same width as the yellow area of interest (AOI) box.
- The height of the green box is unrestricted, but typically it will be very small (10-20 slices). It represents a Slice Count number of slices (text box), that will be milled.

# Demonstration: Sample preparation

Prerequisites: Fiducial marker placed and found Area of interest defined

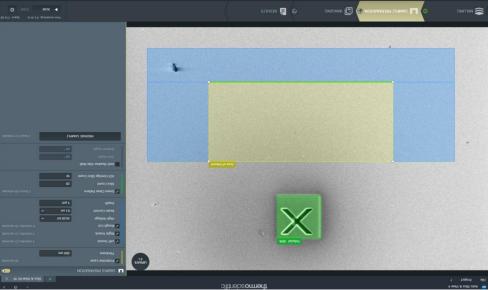
# Mill the trenches

- Ticking the check box(es) enables the option(s), corresponding areas within the
- image are colored in the same way as in the module.

  The time value on the right side next to the corresponding items shows the estimated milling time. The Beam current and milling area dimensions are the

main factors which influence the time. The blue rough cut and trench cut areas, just as the yellow area of interest (or Protective layer area) can be modified graphically by dragging and dropping the selection boxes on the corners and sides of each rectangle. The Left Trench and Right Trench can not be

used simultaneously with the Anti-Shadow Side Wall.



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